Performance of Large Area Thin-Film CdTe Detector in Diagnostic X-Ray Imaging

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ABSTRACT

Significant advancement in thin-film cadmium telluride (CdTe) deposition techniques in recent years has made this material attractive for the development of low-cost large area detector. Here we evaluate the intrinsic performance of the detector for a range of energies relevant to diagnostic imaging applications, such as fluoroscopy. The input x-ray spectra for a set of tube potentials ranging from 70 to 140 kVp were computed with the tungsten anode spectral model using interpolating polynomials (TASMIP) based on the measured output of our diagnostic x-ray simulator. Frequency-dependent detector performance analysis was conducted through Monte Carlo simulations of energy deposition within the detector. Intrinsic modulation transfer functions (MTF), noise power spectra (NPS), and detective quantum efficiencies (DQE) were computed for a set of CdTe detectors of varying thickness, from 100 to 1000 μ m. MTF behavior at higher frequencies was affected by thickness and input energy, NPS increased with film thickness and energy, and the resultant DQE(*f*) decreased with increasing the input energy, but increased with the thickness of the detector. We found that the optimal thickness of CdTe under diagnostic x-ray beam is in the range of 300 to 600 μ m. Physical properties of CdTe, such as the high atomic number and density, used in direct detection configuration, together with the recently established thin-film manufacturing techniques makes this technology a promising photoconductor for large-area diagnostic flat panel imaging.

Keywords: Monte Carlo; CdTe Detector; Photovoltaic; Thin Film; TASMIP; DQE; X-Ray Imaging

1. Introduction

Introduction of digital radiography systems and successive use of flat panel detectors revolutionized the field of diagnostic imaging. Wide dynamic range, high image quality, real-time image acquisition and processing, precise image recording, and ease of remote access are among the most prominent improvements. One of the decisive factors contributing to further advancements remains the continuous development of different x-ray detecting materials, from traditional phosphor screens in combination with secondary photodetectors for indirect detection to use of thin-film photoconductors in direct detection systems. The latter approach offers a twofold benefit: simpler device structure resulting in lower manufacturing cost, and a high potential of providing images of superior contrast and sharpness due to inherently low signal spreading within the detector.

In the direct detection approach x-rays are absorbed by a photoconductor layer and converted to electron-hole

pairs, which are then collected as electric charges on storage capacitors. Up to now amorphous selenium (a-Se) is the only photoconductor developed into direct detection type commercial medical imagers, for both general radiography and mammography applications [1-4]. Detectors are based on a-Se offer superior spatial resolution due to the simple conversion process. However, low xray absorption and high effective ionization energy (~50 eV) result in inadequate sensitivity, especially important for low exposure levels of fluoroscopic mode [5].

To overcome this problem, materials of high atomic numbers and densities, such as mercuric iodide (HgI₂), lead iodide (PbI₂) [6-11], lead oxide (PbO) [12], thallium bromide (TlBr) [13], and cadmium telluride/cadmium zinc telluride (CdTe/CdZnTe) [14-17], have been suggested to replace a-Se. All of these materials possess effective ionization energy about 10 times lower than that of a-Se, substantially large band gaps, necessary for minimization of leakage currents at room temperature, and high mobility-lifetime product, providing effective charge collection [9,18,19].

Due to large area requirements imposed on practical medical detectors all of these materials are investigated in polycrystalline (thin-film) rather than single crystal form. This quest entails development of proper techniques for thin-film deposition in order for the material to be commercially viable. Since a-Se has been studied the longest, by now the capabilities to manufacture highquality films as thick as 1 mm have been proven. For other photoconductors this is still a subject of an ongoing research, rendering the use of some of the materials rather challenging. For example, strong temperature dependence of TlBr's conductivity makes it difficult to operate at room temperature [13]; poor response time and some limitations on film thickness are detrimental to PbI₂-based device performance [10]; chemical stability, nonuniform sensitivity, low carrier mobilities, and high levels of dark currents are still somewhat problematic in HgI₂ devices [10,11], although the last material appears to be one the most promising.

Recent developments in large area photovoltaic applications of CdTe have moved this photoconductor to the frontiers of thin-film manufacturing [20]. While the typical thickness of a solar cell is under 10 μ m, the device deposition methodologies and post-deposition treatments for grain boundary passivation are essentially the same, and are successfully implemented in the fabrication of xray detectors up to 600 μ m thick [15,16].

Even though the average atomic number of CdTe is lower than that of HgI_2 , their absorption properties are very similar over a wide range of kV x-ray energies. Comparison of absorption coefficients [21] in **Figure 1** demonstrates that for energies up to the k-edge of mercury (83 keV) both materials are equally superior to a-Se. Coincidently, even for the spectra corresponding to higher kV potentials (up to 140 kVp) most of x-rays have energies in that range. Proven outstanding radiation hardness of CdTe [22-26] makes it an ideal candidate for imaging application.

We have previously explored the use of thin-film CdTe detector in radiation therapy imaging [27]. Up to now no systematic theoretical analysis of the thin film CdTe detector for diagnostic x-ray imaging has been performed. Here we investigate the theoretical performance of thin-film CdTe of thickness from 100 to 1000 µm under a range of energies relevant to high-energy diagnostic imaging applications, from 70 kVp to 140 kVp, using Monte Carlo (MC) radiation transport package MCNP5 [28]. In this approach only energy deposition is evaluated, with no assumptions made about the electronic properties of CdTe. Therefore our calculations provide the upper-limit estimate for the material performance in an idealized case of complete charge collection. Our goal is to find a range of optimal thickness of



Figure 1. Comparison of absorption coefficients for Se, CdTe, and HgI₂.

thin film CdTe which maximizes the detective quantum efficiency DQE(f) for different x ray energies and compare CdTe detector performance to that of other photoconductors.

2. Methods and Materials

2.1. Input Spectra

The input x-ray spectra for the detector performance study were obtained for a set of kV potentials ranging from 70 to 140 kVp. For this purpose we employed a tungsten anode spectral mode using interpolating polynomials (TASMIP) [29] technique, that allows computing x-ray spectra based on the measured output of our Ximatron clinical simulator unit (Varian, Palo Alto, CA). The TASMIP is not a semi-empirical algorithm and uses no physical assumptions regarding x-ray production, but rather interpolates measured constant potential x-ray spectra published by Fewell *et al.* [30]. TASMIP has been shown to accurately reproduce both the kV-dependent spectral shape and output fluence for x-ray machines employing tungsten target.

The x-ray output of the simulator was measured in the units of mR/mAs at a distance of 100 cm from the focal spot using an Unfors Xi External Detector. Output was measured at 200 mA, 50 ms (10 mAs) with 0, 1, 2, 3, 4, and 5 mm added aluminum filtration for a set of kVp values in the range from 40 to 125, as shown in **Figure 2**. The points show the actual measured values, while the solid lines represent four-term (third order) polynomial fits for each filtration. The attenuation curves in **Figure 3** were calculated based on these fitted outputs.

Unfiltered tungsten spectra from Fewell *et al.* [30] were tabulated for 70, 80, 90, 100, 120, 130, and 140 kVp and were linearly interpolated to obtain spectra with 1 keV interval. These tabulated data corresponding to the spectra labeled EI1 though EI8 on pages 43 - 45 of [28]. The attenuation curves of these unfiltered Fewell's spectra were calculated based on the attenuation coefficients of aluminum from Physics Laboratory of National Insti-



Figure 2. The simulator output for different values of added aluminum filtration. Points show the measured values, and the solid lines represent third-order polynomial fits for each filtration.



Figure 3. Matched attenuation curves of simulator x-ray and Fewell's spectra for different kVp based on the leastsquare approach. The points are attenuation values calculated from the modified Fewell's spectra, and the corresponding solid lines represent attenuation profiles calculated from our simulator output.

tute of Standard and Technology (NIST). To compensate for probable differences in the x-ray tube housing attenuation values at each kVp, additional thicknesses of aluminum were needed to compensate for the inherent filtration. The least square approach was used to minimize the percent difference in attenuation values between our simulator's and the Fewell's spectra, as shown in **Figure 3**. Here the points are attenuation values calculated from the modified Fewell's spectra, and the corresponding solid lines represent attenuation profiles calculated from our simulator output data. Additional aluminum thickness needed to match the Fewell's spectra to the attenuation levels of our simulator are given in **Table 1**.

Once the Fewell's spectral shapes were slightly hardened to best fit our simulator attenuation values, the number of photons for each spectrum was normalized to the corresponding output of the simulator with no added filtration. Based on these spectra modified with addi-

 Table 1. Aluminum filtration added to match the Fewell's spectra.

Potential (kVp)	70	80	90	100	110	120	130	140
Added aluminum thicknesses, mm	0.557	0.700	0.802	1.037	0.854	0.818	0.727	0.587

tional aluminum thicknesses, we were able to calculate the polynomial interpolating coefficients using the following equation

$$\Phi[E] = a_0[E] + a_1[E] kVp + a_2[E] kVp^2 + a_3[E] kVp^3$$
(1)

with these interpolating coefficients we were able to compute the simulator x-ray spectra at any kVp value. We generated simulator spectra shown in **Figure 4** for 70, 80, 90, 100, 110, 120, 130, and 140 kVp values. The two peaks present in higher kVp spectra correspond to K α and K β edges of tungsten. The average percentage deviations between the modified spectra and the final interpolated spectra were between 0.1% and 1.9%. These spectra were utilized for source specification in our Monte Carlo simulations.

2.2. Detector Simulation

2.2.1. Exit Spectra

During an imaging process the source beam spectrum is modified before reaching a detector by first going through a patient. To properly account for this effect we obtained the exit spectra, which are the energy spectra of the primary photons transmitted through a 20 cm thick water phantom representing a patient. Figure 5(a) shows the MC simulation geometry used, where the source of photons having the above-calculated spectra is placed at a distance of 100 cm from the phantom. The exit spectra were acquired with MCNP tally F1 at the surface of thinfilm CdTe detector, located 20 cm below the water phantom according to the clinical application with a source to film distance (SFD) of 140 cm. Figures 6(a) and (b) show the primary photon spectra before and after the water phantom for energies of 80 kVp and 140 kVp, respectively. The relative photon intensity in both graphs was calculated based on the number of photons reaching the surface of CdTe detector per source particle (number of histories). Exit spectra demonstrate a two-fold effect of the presence of the water phantom, namely reduction in beam intensity due to absorption and scatter, and a slight beam hardening.

Only primary photon beams were used to evaluate the performance characteristics of the detector. In all simulations we used CdTe thin-film density $\rho = 5.86$ g/cm³. The electron cut-off energy (ECUT) was chosen so that the electron range at ECUT is less than 1/3 of the smallest dimension in the dose scoring region, 0.02 MeV for 20



Figure 4. Simulator spectra from 70 kVp to 140 kVp computed by polynomial interpolation of modified Fewell's spectra.



Figure 5. (a) Schematic illustration of the geometry setup used in Monte Carlo simulations of energy deposition; (b) Geometry setup for line spread function simulation.

micron scoring slit [31,32]. The cut-off energy for photons was set to 0.01 MeV, with coherent, photonuclear and Doppler interactions turned off.

2.2.2. Pre-Sampling Modulation Transfer Function (MTF)

Modulation transfer function is an important characteristic of a detector, ultimately defining its resolution. It represents the capability of the detector to transfer signal with minimal spreading. In our MC simulations presampling MTF was obtained in the geometry shown in **Figure 5** for the thin-film CdTe detector of different thickness, 100, 300, 600, and 1000 μ m. X-ray beams with exit spectra having potential energies of 70 to 140 kVp were set to fall normally at the detector surface



Figure 6. Primary photon spectra before and after a 20-cm thick water phantom for (a) 80 kVp; (b) 140kVp.

through a narrow, 2 μ m wide, slit, following a typical setup for line spread function LSF(x) measurement, as shown in **Figure 5(b)** [33]. For frequency dependent MTF(*f*) simulation, the detector was divided into 512 strips on each side of the slit source with a width of 10- μ m, which according to the Nyquist criterion gave a cutoff frequency of 50 mm⁻¹. Energy deposition within each strip was acquired with *F8 tally. The MTF(*f*) was calculated by performing a fast Fourier transform (FFT) of LSF(x) with Hanning window method. The total number of points of 1024 produced smooth MTF(*f*) curves with enough sampling around zero frequency.

2.2.3. Noise Power Spectrum (NPS)

Noise transfer properties of the detector were evaluated through simulations of the frequency-dependent noise power spectra (NPS) or Wiener spectra. The mean square departure of signal from its average value is the variance and the analysis of this variance into frequency components gives the noise power spectrum [34]. The simulation geometry was similar to that used to obtain MTF. A $30 \times 40 \text{ cm}^2$ photon beam was set perpendicularly incident on the X-Y plane of the detector. One-dimensional (1-D) NPS was analyzed by a synthesized slit technique [34,35]. The energy absorbed per scoring bin, d_x , was recorded by *F8 tally in the non-overlapping slits of 512 bins per slit. Each slit had dimensions of $0.002 \times 3 \text{ cm}^2$, providing a Nyquist frequency of 25 mm⁻¹ in x direction.

The absorbed energy distributions per bin were Fourier transformed using a 1-D FFT to yield frequency dependent power spectra. Total of 420 slits were averaged to yield the simulated NPS in units of MeV²mm², calculated as [36,37]:

$$NPS(f) = \frac{x_0 y_0}{N_x N_y} \left\langle \left| DFT(\Delta d_{x,y}) \right|^2 \right\rangle$$
(2)

here x_0 and y_0 are the x and y spacing of the discrete values respectively; $N_x = 1$ and $N_y = 512$ are the number of elements in x and y dimensions, respectively; $d_{x,y}$ is the energy deposited (in MeV) within the (x, y)-th element, $\Delta d_{x,y} = d_{x,y} - \langle d_{x,y} \rangle$, and $\langle d_{x,y} \rangle$ was the average energy deposited per scoring bin.

The simulations of noise power spectra are quite computer demanding on computer CPU time. To ensure that the statistical error per scoring bin is below 10%, we ran at least 10^8 photon histories per detector configuration.

2.2.4. Detective Quantum Efficiency (DQE)

The detective quantum efficiency (DQE) has become the best single descriptor of radiographic detector performance. By definition, DQE is the squared ratio of the signal-to-noise (SNR) at the detector output to that at the detector input as a function of spatial frequency f. It gives a measure of how efficiently the imaging system makes use of the information content of a radiation beam. For an ideal imaging system, the DQE is equal to 1, but in reality it is degraded by different sources of noise associated with the system.

DQE at zero frequency, DQE(0), is related to energy absorption properties only, it is the maximum DQE of the detector that could be achieved. When taking x-ray quantum detection noise into account, the DQE(f) can be expressed as [38,39]:

$$DQE(f) = \frac{A_0^2 MTF^2(f)}{\overline{q_0} NPS(f)}$$
(3)

where A_0 is the mean signal value at the detector output and q_0 is the incident x-ray fluence. In our MC simulations, pulse height tally *F8 was used to record the energy deposition within each detector element, averaged into the mean signal value A_0 . Based on simulated MTF and NPS we found frequency-dependent detective quantum efficiencies for a set of kVp values for CdTe detectors of varying thickness. We note that DQE(f) obtained for each CdTe film thickness is a pre-sampling or intrinsic characteristic of the detector.

2.2.5. Conversion Gain

The next part of analysis involves assessment of the gain associated with conversion of the energy deposited by x-rays into electron-hole pairs in CdTe. This stage is termed amplification stage in the multi-stage (cascaded) linear systems theory [40]. To evaluate this gain we use the energy required for creating one electron-hole pair in CdTe, $W_{CdTe} \sim 5$ eV for polycrystalline material [41,42] (this value is very close to 4.43 eV measured for crystalline CdTe [43]). The amount of energy deposited in CdTe per incoming X-ray is defined by the mean signal value A_0 , and therefore depends on CdTe thickness. The maximum amplification gain g can be estimated as

$$g = \frac{A_0}{W_{\rm CdTe}} \tag{4}$$

and represents the upper limit estimate for the number of electron-hole pairs generated in a certain volume of CdTe.

3. Results and Discussion

3.1. MTF

The modeled pre-sampling MTF of thin film CdTe with thicknesses from 100 to 1000 μ m under 80 kVp beam is shown in **Figure 7(a)**. As expected, MTF of CdTe decreases with increasing the thickness, but the decrease in MTF becomes moderate for films thicker than 300 μ m. At the spatial frequency of 5 mm⁻¹, MTF of 300 μ m decreases about 6.1% compared to that of 100 μ m, while the MTF of 600 μ m decreases only 1.4% compared to that of 300 μ m. Even less of a relative decrease, only 0.2% compared to that of 600 μ m, is observed for 1000 μ m thick film. General trend of MTF reduction with the increasing detector thickness is the result of the increase in both the amount of secondary particle's scatter, and the fraction of re-absorption of k-fluorescence x-rays.

The MTF of 600 µm thick CdTe under different energies from 70 kVp to 120 kVp is shown in Figure 7(b). For the frequency range of about 3 to 15 mm⁻¹, the lowest energy beam produces lowest MTF. This is related to the larger portion of incoming photons having energies just above the k-edges of both Cd (26.7 keV) and Te (31.8 keV). The higher absorption (see Figure 1) results in production of a larger number of fluorescence photons, which can be re-absorbed up to 150 µm away from the origin. At higher frequencies (see Figure 7(b), inset), the MTF is more degraded at the higher beam energies due to the increase in probability of Compton interactions, resulting in scattered particles depositing their energy close to the first interaction site. The effective path lengths of recoil electrons increase with the increasing energy, resulting in increased lateral spread within the detector. These are consistent with the findings of previous researchers [19,44,45].

3.2. NPS

Quantum noise is an unavoidable result of statistical fluctuations in the number of x-rays interacting within



Figure 7. (a) MTF of CdTe with thicknesses of 100, 300, 600, and 1000 μ m under 80 kVp beam; (b) MTF of 600 μ m CdTe under energies from 70 kVp to 120 kVp.

the detector and statistical fluctuations in the number of electrons produced as the result of each interaction. As shown in **Figure 8(a)**, noise power spectrum increases with the thickness of the detector. This is well expected since more photons are absorbed as the detector thickness increases. Comparison of **Figures 8(a)** and **(b)** indicates that for the same film thickness the noise power also increases with increasing energy, which is probably due to increase in energy deposited per interacting photon.

Another trend evident from **Figure 8** is that noise is strongly correlated, especially for thicker CdTe films. As x-rays traverse the detector layer they produce ionizing particles, which deposit energy in CdTe layer through a large number of discrete interactions along the path of each particle, leading to correlated quantum noise. We fitted each NPS with a Lorentzian function

 $y = y_0 + \frac{2A}{\pi} \times \frac{w}{4x^2 + w^2}$, where w is the full width at half

maximum, and y_0 and A are fitting parameters. The fits are shown as solid lines in **Figure 8**. The correlation length in mm, reflecting the smallest feasible pixel size for the detector, was estimated as w^{-1} . Typical values obtained for 300 to 1000 µm thick CdTe were in the range of 0.1 mm, which is within the range of usual pixel sizes employed in digital imagers [5].



Figure 8. Noise power spectra under (a) 80 kVp beam and (b) 120 kVp beam.

3.3. DQE

Shown in Figure 9 are the results for DOE(f) of 100 to 1000 µm thick CdTe. These were calculated using Equation (3), based on MTF and NPS curves shown in Figures 7 and 8, where NPS dependences were fitted with Lorenzian functions. DQE(f) improves with increasing thin film CdTe thickness due to increase in number of absorbed photons. However, a thicker detector also provides longer paths for the lateral spread of secondary electrons and photons, resulting in a loss of spatial resolution and increase of noise, as shown in Figure 7 and Figure 8. As evident from Figure 9(a) there is little improvement in DQE(f) as thickness increases beyond 600 µm. Effect of both the thickness and beam energy on DQE is shown in Figure 9(b): DQE(f) decreases for higher kVp, mainly due to decrease in interaction probability of higher energy photons, as expected from lower absorption coefficient (Figure 1).

To summarize the trends in energy absorption with thickness and kVp we plot in **Figure 10** DQE(0) values obtained from DQE(*f*) analysis. Here we clearly observe the increase in the absorption efficiency of the detector with the increasing thickness, becoming very moderate after 600 μ m, especially for lower energies. For example, under 80 kVp, DQE(0) of 300 μ m CdTe is about 59.7% more of that of 100 μ m, however, the DQE(0) of 1000 μ m is only about 7.4% more than that of 600 μ m.



Figure 9. Computed DQE(f). (a) Under 80 kVp; (b) Under 120 kVp.



Figure 10. DQE(0) of CdTe detector vs the film thickness in µm for 80 and 120 kVp x-ray spectra.

3.4. Conversion Gain

Based on the energy deposition modeled with MC and using Equation (4) we estimate the average number of electron-hole pairs created in the CdTe layer per 1 cm² area of the detector. The resultant dependences of generation rates on the CdTe thickness are shown in **Figure 11**, where a log-log scale is used for clarity. The dependence is close to $(1-\exp(-\alpha t))$ up to the CdTe thickness *t* of the order of the average x-ray penetration depth, saturating for thicker films.

Here we can also consider the noise associated with the gain variance that can be estimated [46] based on the number of electron-hole pairs created N and Fano factor



Figure 11. Electron-hole pair generation per incoming photon over 1 cm^2 area of the CdTe detector for different diagnostic x-ray spectra.

F (~0.1 for most crystalline semiconductors [47]) as $\sigma_g \sim \sqrt{FN}$. The resulting relative gain variance is $\sigma_g/g \leq 2\%$ for thickness of CdTe of 100 µm and larger.

3.5. Comparison with Other Photoconductors

We compare characteristics of CdTe with other photoconductors, namely a-Se and HgI_2 . The former is used in the only commercially available direct detection type system, while the latter represents a more promising of the higher atomic number materials. Due to the presence of absorption edges a mere comparison of absorption coefficients in **Figure 1** is not sufficient for adequate understanding of the frequency-dependent detector performance at different kVp values.

MTF evaluation shown in **Figure 12** illustrates this non-trivial behavior. As expected, the lowest absorption resulting in the lowest interaction probability is solely responsible for the minimal signal spreading and the highest of all three materials MTF of a-Se. However, even though HgI₂ has the highest atomic number and therefore the highest absorption, its MTF is still higher than that of CdTe for 80 kVp x-ray spectrum. This is related to the additional signal spreading due to the longer path length of fluorescence photons produced from xrays with energies just above the k-edges of both Cd and Te [19]. At 120 kVp, though, where more photons with energies above HgI₂ k-edge are present in the incoming beam, this is no longer the case: MTF of CdTe is higher than mercuric iodide's, as evident from **Figure 12(b)**.

The final DQE(f) calculated for the three materials are shown in **Figure 13** for photon two spectra, 80 and 120 kVp. The latter spectrum produces the highest DQE for CdTe for frequencies f = 0.4 and above. For example, at f= 10, still within practical interest for kV imaging applications, DQE values for CdTe, HgI₂, and a-Se are 0.52, 0.45, and 0.31, respectively.

To verify our simulation results, we compared our DQE values with those published previously. The maximum



Figure 12. MTF of three photoconductors with thickness of 300 µm. (a) Under 80 kVp beam; (b) Under 120 kVp beam.



Figure 13. DQE(f) of three photoconductors with thickness of 300 µm. (a) Under 80 kVp beam; (b) Under 120 kVp beam.

measured DQE value of 0.7 for 350 μ m thick CdZnTe was obtained in the study of S. Tokuda, *et al.* [17] for 70 kVp beam. This is close to calculated in this work DQE(0) = 0.76 under similar conditions (80 kVp, 300 μ m thickness).

The value of DQE(0) for 300 µm thick a-Se under 80 kVp spectrum of our simulation is ~0.53. In the study of Zhao et al. [1], the calculated DOE(0) of 300 µm under a spectrum of 70 kVp is about 0.6 due to the Swank factor and the broad x-ray spectrum using the cascade systems model. These two values are quite close taking into account the differences in calculation approaches and the input spectra. Du et al. [6] studied physical vapor deposition (PVD) polycrystalline HgI₂ with thickness range from 210 µm to 300 µm under an x-ray spectrum of 72 kVp. Their theoretical DQE(0) of 210 μ m thick HgI₂ prototype calculated with cascaded system is about 0.6, taking quantum efficiency and Swank factor into account. This is in agreement with our calculated DQE(0) = 0.78for 300 µm HgI₂ under 80 kVp, taking into account the thickness and spectra differences.

While intrinsic imaging properties of HgI_2 and CdTe are close, comparison of their electronic properties favors the latter material, whose carrier mobilities are at least an order of magnitude higher [48], making it more attractive for use in radiation detectors.

3.6. Device Operation

In order to separate and collect the charged carriers generated in the existing CdTe based radiation detectors, a strong electric field $\sim 10^3 - 10^4$ V/cm is typically created by application of the external biasing voltage across the sensitive volume of the device. In this approach the value of the noise due to leakage current associated with the application of a large bias (~ 1000 V for ~ 1 mm thick device) becomes the primary concern. Additionally, problems of charge trapping and polarization effect specific to crystalline CdTe strongly contribute to drift in the detector response.

With easier to grow, and typically thinner polycrystalline semiconductor films, it is possible to utilize a photovoltaic (PV) mode of operation, where a junction created at the interface of differently doped semiconductors and/ or semiconductor-metal provides the built-in electric field. In the photovoltaic mode the problems related to biasing do not come into play. However, the major difficulty arises from incomplete charge collection due to localization of the electric field to a region that can be much shorter than the detector thickness.

A number of groups verified the feasibility of x-ray detectors operating in PV mode, including those based on Si [49], CdTe [50,51], and GaAs [52]. In the case of GaAs it was demonstrated that the depletion region can extend over the entire film thickness of 80 µm, resulting

in equally efficient charge collection of ~93% for both PV and biased modes of operation. While it is the state of the art GaAs structure with non-uniform doping profile that makes such a field distribution possible, it provides a proof of PV mode concept and points toward the need for a stronger materials science effort in x-ray detector research. So far a similar undertaking in polycrystalline CdTe doping yielded detectors with thickness of up to 150 μ m achieving full depletion at bias of <1 V [53].

At this time the deposition techniques, material processing, and device engineering approaches for CdTe come mostly from the commercially successful field of polycrystalline thin-film CdTe solar cells. Based on the established results of thin-film photovoltaic applications, the built-in field of ~10⁴ V/cm is induced in the vicinity of CdTe/CdS where the CdS layer can be extremely thin (below 1 micron) and can be neglected from the point of view of charge carrier generation. The electric field region in a much thicker (thin-film) CdTe extends over a few micron depletion width L_d from the metallurgical junction.

Assuming, for absorption purposes, CdTe thickness much greater than L_d the arrangement becomes superficially analogous to that of the classical structure of crystalline silicon p-n junction photovoltaic device, which remains the most established type of commercially available solar cells. In those devices charge carrier generation spans distances orders of magnitude greater than the depletion width $L_{\rm d}$ that is on the order of microns. The consensus for the case of Si is that the carriers generated far from the built-in field region are collected mostly through the diffusion currents. The key factor behind efficient diffusion currents in crystalline Si is a significant diffusion length $\sqrt{D\tau}$ comparable to the device thickness, where D is the diffusion coefficient and τ is the minority carrier lifetime. Simply stated, it is a high material quality of crystalline Si that provides long enough $\tau \sim$ 1 ms [48] and efficient diffusion (note that in some analyses the product of mobility and τ proportional to $D\tau$ is taken to be a figure of merit).

Extending the diffusion current argument over to the case of CdTe may seem unsuccessful if one use the lifetime $\tau \sim 1 \mu s$ measured for crystalline X-ray detectors [48]. However, the latter quantity does not describe the transport phenomena in polycrystalline films where the non-equilibrium electrons and holes are spatially separated by the built-in electric field at grain boundaries. Such a separation can exponentially suppress recombination making charge carrier lifetimes orders of magnitude longer. This understanding is consistent with the fact that CdTe based PV cells retain their high efficiencies in the thickness range of 10 μ m and above [54]. Preliminary measurements of carrier lifetime for ~100 μ m thick films have demonstrated values at least 10 times higher [53] than those commonly accepted for the single crystal CdTe. It is only a speculation at this time, but the effective diffusion length in polycrystalline CdTe may be comparable to that of crystalline Si.

The latter speculation is consistent with the results of our device operation modeling (with SCAPS software; not presented here) based on the baseline input parameters commonly accepted for CdTe based PV [55]. That modeling shows that device voltage is a weak function of the CdTe layer thickness, saturating for devices thicker than 100 microns. The current, however, increases several times when the device thickness changes from 10 to 100 microns saturating for devices thicker than ~300 microns. This is consistent indeed with the above-mentioned picture of crystalline Si devices with the electric filed limited to near the junction and significant contribution of the diffusion current to the output signal.

In view of these observations, CdTe device can be operated in two regimes: 1) if the output current is measured, then applying external bias is beneficial for boosting signal collection; 2) in the voltage measurement setup, carrier collection without external biasing (photovoltaic mode of operation) can provide strong enough signal for a device much thicker than the depletion width. Comparison between these two regimes cannot be made based on theoretical estimates only since there are many factors affecting the leakage current and the transport properties in polycrystalline devices. For example, addition of CdS as buffer layer has been shown to dramatically decrease the leakage current [14-17]. More experimental studies on electronic properties of >100 μ m thick polycrystalline CdTe films and detectors are called upon.

4. Conclusions

We calculated x-ray spectra for our clinical diagnostic x-ray simulator unit for tube potential voltages from 70 to 140 kVp employing a tungsten anode spectral mode using interpolating polynomials (TASMIP) algorithm. Using these spectra as input we studied the frequency-dependent characteristics, MTF, NPS, and DQE, of thin film direct detection CdTe imager by Monte Carlo simulations of energy deposition. Our results showed that the detector based on CdTe is capable of achieving a high resolution as well as high quantum efficiency. We found the optimal thickness of thin film CdTe for diagnostic x-ray imaging to be in the range of 300 to 600 µm.

Utilization of high-density and high-atomic number photoconductors is especially important for lowering the exposure levels of fluoroscopic imaging mode, since they are capable of not only detecting a larger fraction of the incident radiation, but are also likely to reduce the lateral spread of secondary electrons and photons. Physical properties of thin-film CdTe, such as mechanical and chemical stability, together with its outstanding radiation hardness and recently developed film deposition techniques, make this photoconductor an ideal choice for large-area direct detection system employed in x-ray diagnostic imaging applications.

REFERENCES

- W. Zhao and J. A. Rowlands, "Digital Radiology Using Active Matrix Readout of Amorphous Selenium: Theoretical Analysis of Detective Quantum Efficiency," *Medical Physics*, Vol. 24, No. 12, 1997, pp. 1819-1833. doi:10.1118/1.598097
- [2] W. Zhao, I. Blevis, S. Germann, J. A. Rowlands, D. Waechtcher and Z. S. Huang, "Digital Radiology Using Active Matrix Readout of Amorphous Selenium: Construction and Evaluation of a Prototype Real-Time Detector," *Medical Physics*, Vol. 24, No. 12, 1997, pp. 1834-1843. doi:10.1118/1.598098
- [3] D. L. Lee, L. K. Cheung, B. G. Rodricks and G. F. Powell, "Improved Imaging Performance of a 14×17-Inch Direct Radiography System Using Se/TFT Detector," *Proceedings of SPIE*, Vol. 3336, 1998, pp. 14-23.
- [4] A. Tsukamoto, S. Yamada, T. Tomisaki, M. Tanaka, T. Sakaguchi, K. Suzuki and M. Ikeda, "Development and Evaluation of a Large-Area Selenium-Based Flat-Panel Detector for Real-Time Radiography and Fluoroscopy," *Proceedings of SPIE*, Vol. 3659, 1999, pp. 14-23.
- [5] L. E. Antonuk, K.-W. Jee, Y. El-Mohri, M. Maolinbay, S. Nassif, X. Rong, Q. Zhao, J. H. Siewerdsen, R. A. Street and K. S. Shah, "Strategies to Improve the Signal and Noise Performance of Active Matrix, Flat-Panel Imagers for Diagnostic X-Ray Applications," *Medical Physics*, Vol. 27, No. 2, 2000, pp. 289-306. doi:10.1118/1.598831
- [6] H. Du, L. E. Antonuk, Y. El-Mohri, Q. Zhao, Z. Su, J. Yamamoto and Y. Wang, "Investigation of Signal Behavior of Polycrystalline HgI2 at Diagnostic Energies of Prototype, Direct Detection, Active Matrix, Flat-Panel Imagers," *Physics in Medicine and Biology*, Vol. 53, No. 5, 2008, pp. 1325-1351. doi:10.1088/0031-9155/53/5/011
- [7] K. S. Shan, P. R. Bennett, M. Klugerman, L. P. Moy, G. Entine, D. R. Ouimette and R. Aikens, "Lead Iodide Films for X-Ray Imaging," *Proceedings of SPIE*, Vol. 3032, 1997, pp. 395-404.
- [8] R. A. Streat, J. T. Rahn, S. E. Ready, K. S. Shah, P. R. Bennett, Y. N. Dmitriyev, P. Mei, J. P. Lu, R. B. Apte, J. Ho, K. Van Schuylenbergh, F. Lemmi, J. B. Boyce and P. Nylen, "X-Ray Imaging Using Lead Iodide as a Semiconductor Detector," *Proceedings of SPIE*, Vol. 3659, 1999, pp. 36-47.
- [9] G. Zentai, L. Partain, R. Pavlyuchkova, G. Virshup, A. Zuck, L. Melekhov, O. Dagan, A. Vilensky and H. Gilboa, "Large Area Mercuric Iodide X-Ray Imager," *Proceedings of SPIE*, Vol. 4682, 2002, pp. 592-600.
- [10] Y. Kang, L. E. Antonuk, Y. El-Mohri, L. Hu, Y. Li, A. Sawant, Z. Su, Y. Wang, J. Yamamoto and Q. Zhao, "Examination of PbI2 and HgI2 Photoconductive Materials for Direct Detection, Active Matrix, Flat-Panel Imagers for Diagnostic X-Ray Imaging," *IEEE Transactions on Nuclear Science*, Vol. 52, No. 1, 2005, pp. 38-45.

doi:10.1109/TNS.2004.843135

- [11] Z. Su, L. E Antonuk, Y. El-Mohri, L. Hu, Hong Du, A. Sawant, Y. Li, Y. Wang, J. Yamamoto and Q. Zhao, "Systematic Investigation of the Signal Properties of Polycrystalline HgI2 Detectors under Mammographic, Radiographic, Fluoroscopic and Radiotherapy Irradiation Conditions," *Physics in Medicine and Biology*, Vol. 50, No. 12, 2005, pp. 2907-2928. doi:10.1088/0031-9155/50/12/012
- [12] M. Simon, R. A. Ford, A. R. Franklin, S. P. Grabowski, B. Menser, G. Much, A. Nascetti, M. Overdick, M. J. Powell and D. U. Wiechert, "PbO as Direct Conversion X-Ray Detector Material," *Proceedings of SPIE*, Vol. 5368, 2004, pp. 188-199.
- [13] D. R. Ouimette, S. Nudelman and R. S. Aikens, "A New Large-Area X-Ray Image Sensor," *Proceedings of SPIE*, Vol. 3336, 1998, pp. 470-476.
- [14] S. Adachi, N.Hori, K. Sato, K. Uehara, Y. Izumi, H. Nagata, Y. Yoshimura and S. Yamada, "Experimental Evaluation of a-Se and CdTe Flat-Panel X-Ray Detectors for Digital Radiography and Fluoroscopy," *Proceedings of SPIE*, Vol. 3977, 2000, pp. 38-47.
- [15] S. Tokuda, S. Adachi, T. Sato, T. Yoshimuta, H. Nagata, K. Uehara, Y. Izumi, O. Teranuma and S. Yamada, "Experimental Evaluation of a Novel CdZnTe Flat-Panel X-Ray Detector for Digital Radiography and Fluoroscopy," *Proceedings of SPIE*, Vol. 4320, 2001, pp. 140-147.
- [16] S. Tokuda, H. Kishihara, S. Adachi, et al., "Large-Area Deposition of a Polycrystalline CdZnTe Film AND Its Applicability to X-Ray Panel Detectors with Superior Sensitivity," *Proceedings of SPIE*, Vol. 4682, 2002, pp. 30-41.
- [17] S. Tokuda, H. Kishihara, S. Adachi and T. Sato, "Improvement of the Temporal Response and Output Uniformity of Polycrystalline CdZnTe Films for High Sensitivity X-Ray Imaging," *Proceedings of SPIE*, Vol. 5030, 2003, pp. 861-870.
- [18] C. Choi, C. Kyun, S. Kang and S. Nam, "Comparison of Compound Semiconductor Radiation Films Deposited by Screen Printing Method," *Proceedings of SPIE*, Vol. 6510, 2007, pp. 651042-1-651042-8.
- [19] M. Hoheisel, J. Giersch and P. Bernhardt, "Intrinsic Spatial Resolution of Semiconductor X-Ray Detectors: A Simulation Study," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 531, No. 1-2, 2004, pp. 75-81. doi:10.1016/j.nima.2004.05.077
- [20] B. E. McCandless and J. R. Sites, "Cadmium Telluride Solar Cells," In: A. Lique and S. Hegedus, Eds., *Handbook of Photovoltaic Science and Engineering*, Wiley, New York, 2003, pp. 617-657.
- [21] NIST Database, 2013. http://www.nist.gov/pml/data/xcom/index.cfm
- [22] D. Shvydka, E. Parsai and J. Kang, "Radiation Hardness Study of CdTe Thin Films for Clinical High-Energy Photon Beam Detectors," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 586, No. 2, 2008, pp. 169-173. doi:10.1016/j.nima.2007.11.017

- [23] A. Cavallini, B. Fraboni, W. Dusi, N. Auricchio, P. Chirco, M. Zanarini, P. Siffert and P. Fougeres, "Radiation Effects on II-VI Compound-Based Detectors," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 476, No. 3, 2002, pp. 770-778. doi:10.1016/S0168-9002(01)01674-6
- [24] Y. Eisen, L. G. Evans, S. Floyd, C. Schlemm, R. Starr and J. Trombka, "Radiation Damage of Schottky CdTe Detectors Irradiated by 200 MeV Protons," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 491, No. 1-2, 2002, pp. 176-180. doi:10.1016/S0168-9002(02)01229-9
- [25] D. L. Batzner, A. Romeo, M. Dobeli, K. Weinert, H. Zogg and A. N. Tiwari, "High Energy Irradiation Properties of CdTe/CdS Solar Cells," *Proceedings of 29th IEEE Photovoltaic Specialists Conference*, New Orleans, 19-24 May 2002, pp. 982-985.
- [26] E. Rossa, H. Schmickler, A. Brambilla, L. Verger, F. Mongellaz, "New Development of a Radiation-Hard Polycrystalline CdTe Detector for LHC Luminosity Monitoring," *Proceedings of DIPAC* 2001—*ESRF*, Grenoble, 2001, pp. 94-96
- [27] E. I. Parsai, D. Shvydka and J. Kang, "Design and Optimization of Large Area Thin Film CdTe Detector for Radiation Therapy Imaging Applications," *Medical Physics*, Vol. 37, No. 8, 2010, pp. 3980-3994. doi:10.1118/1.3438082
- [28] F. B. Brown, "MCNP—A General Monte Carlo N-Particle Transport Code," Version 5, LA-UR-03-1987, Los Alamos National Laboratory, Los Alamos, 2003.
- [29] J. M. Boone and J. A. Seibert, "An Accurate Method for Computer Generating Tungsten Anode X-Ray Spectra from 30 to 140 kV," *Medical Physics*, Vol. 24, No. 11, 1997, pp. 1661-1670. doi:10.1118/1.597953
- [30] T. R. Fewell, R. E. Shuping and K. E. Healy, "Handbook of Computed Tomography X-Ray Spectra," HHS Publication (FDA) 81-8162, US Government Printing Office, Washington DC, 1981.
- [31] D. W. O. Rogers, "Low Energy Electron Transport with EGS," *Nuclear Instruments and Methods*, Vol. 227, No. 3, 1984, pp. 535-548. <u>doi:10.1016/0168-9002(84)90213-4</u>
- [32] A. F. Bielajew and D. W. O. Rogers, "Experimental Benchmarks of EGS," In: T. M. Jenkins, W. R. Nelson, A. Rindi, A. E. Nahum and D. W. O. Rogers, Eds., *Monte Carlo Transport of Electrons and Photons*, Prenum, New York, 1988, pp. 115-137. doi:10.1016/0168-9002(84)90213-4
- [33] H. Fujita, D.-Y. Tsai, T. Itoh, K. Doi, J. Morishita, K. Ueda and A. Ohtsuka, "A Simple Method for Determining the Modulation Transfer-Function in Digital Radiography," *IEEE Transactions on Medical Imaging*, Vol. 11, No. 1, 1992, pp. 34-39. doi:10.1109/42.126908
- [34] J. C. Dainty and R. Shaw, "Imaging Science: Principles, Analysis and Evaluation of Photographic-Type Imaging Processes," Academic, London, 1974.
- [35] J. H. Siewerdsen, L. E. Antonuk, Y. EI-Mohri, J. Yorkston, W. Huang and I. A. Cunningham, "Signal, Noise Power Spectrum, and Detective Quantum Efficiency of

Indirect-Detection Flat-Panel Images for Diagnostic Radiology," *Medical Physics*, Vol. 25, No. 5, 1998, pp. 614-628. doi:10.1118/1.598243

- [36] M. B. Williams, P. A. Mangiafico and P. U. Simoni, "Noise Power Spectra of Images from Digital Mammography Detectors," *Medical Physics*, Vol. 26, No. 7, 1999, pp. 1279-1293. doi:10.1118/1.598623
- [37] A. Sawant, L. E. Antonuk, Y. EI-Mohri, Q. Zhao, Y. Li, Z. Su, Y. Wang, J. Yamamoto, H. Du, I. Cunningham, M. Klugerman and K. Shah, "Segmented Crystalline Scintillators: An Initial Investigation of High Quantum Efficiency Detectors for Megavoltage X-Ray Imaging," *Medical Physics*, Vol. 32, No. 10, 2005, pp. 3067-3083. doi:10.1118/1.2008407
- [38] D. A. Jaffray, J. J. Battista, A. Fenster and P. Munro, "Monte Carlo Studies of X-Ray Energy Absorption and Quantum Noise in Megavoltage Transmission Radiography," *Medical Physics*, Vol. 22, No. 7, 1995, pp. 1077-1088. doi:10.1118/1.597593
- [39] I. Cunningham, "Applied Linear-Systems Theory," In: J. Beutel, H. L. Kundel and R. L. Van Metter, Eds., *Handbook of Medical Imaging*, SPIE Press, Bellingham, 2000, pp. 79-159.
- [40] M. J. Yaffe and R. M. Nishikawa, "X-Ray Imaging Concepts: Noise, SNR and DQE," In: J. A. Seibert, G. T. Barnes and R. G. Gould, Eds., Specification, Acceptance Testing and Quality Control of Diagnostic X-Ray Imaging Equipment, Medical Physics Monograph, The American Institute of Physics, New York, 1994, pp. 109-144.
- [41] A. L. Fahrenbruch and R. H. Bube, "Fundamentals of Solar Cells," Academic Press, New York, 1983.
- [42] R. Harju, V. G. Karpov, D. Grecu and G. Dorer, "Electron-Beam Induced Degradation in CdTe Photovoltaics," *Journal of Applied Physics*, Vol. 88, No. 4, 2000, pp. 1794-1801. doi:10.1063/1.1305857
- [43] D. S. McGregor and H. Hermon, "Room-Temperature Compound Semiconductor Radiation Detectors," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 395, No. 1, 1997, pp. 101-124.
- [44] D. L. Lee, L. K. Cheung, E. F. Palechi and L. S. Jeromin, "A Discussion on Resolution and Dynamic Range of Se-TFT Direct Digital Radiographic Detector," *Proceedings of SPIE*, 11 April 1996, Newport Beach, pp. 511-522.
- [45] J. M. Boone, J. A. Seibert, J. M. Sabol and M. Tecotzky, "A Monte Carlo Study of X-Ray Fluorescence in X-Ray Detectors," *Medical Physics*, Vol. 26, No. 6, 1999, pp. 905-916. doi:10.1118/1.598612
- [46] G. F. Knoll, "Radiation Detection and Measurement," 3rd Edition, Wiley, Hoboken, 2000.
- [47] N. Strokan, V. Ajdacic and B. Lalovic, "Measurements of the Fano Factor in Germanium," *Nuclear Instruments and Methods*, Vol. 94, No. 1, 1971, pp. 147-149. doi:10.1016/0029-554X(71)90352-1
- [48] A. Owens and A. Peacock, "Compound Semiconductor Radiation Detectors," *Nuclear Instruments and Methods* in *Physics Research Section A*, Vol. 531, No. 1-2, 2004, pp. 18-37. doi:10.1016/j.nima.2004.05.071

- [49] K. Scharf, "Photovoltaic Effect Produced in Silicon Solar Cells by X- and Gamma Rays," *Journal of Research of the National Bureau of Standards*, Vol. 64A, No. 4, 1960, pp. 297-307.
- [50] G. Entine, R. H. Redus, A. Feyder and P. J. Biggs, "Recent Results with a CdTe Imaging Portal Scanner for Radiation Therapy," *IEEE Transactions on Nuclear Science*, Vol. 40, No. 4, 1993, pp. 1012-1016. doi:10.1109/23.256703
- [51] R. J. Fox and D. C. Agouridis, "CdTe Photovoltaic Gamma-Ray Dosimeter," *Nuclear Instruments and Methods*, Vol. 157, No. 1, 1978, pp. 65-69. doi:10.1016/0029-554X(78)90588-8
- [52] R. A. Achmadullin, V. V. Artemov, V. F. Dvoryankina, G. G. Dvoryankina, Y. M. Dikaeva, M. G. Ermakova, O. N. Ermakovaa, V. B. Chmil, A. G. Holodenkoc, A. A. Kudryashova, A. I. Krikunova, A. G. Petrov, A. A. Telegina and A. P. Vorobiev, "Photovoltaic X-Ray De-

tectors Based on Epitaxial GaAs Structures," *Nuclear Instruments and Methods in Physics Research Section A*, Vol. 554, No. 1-3, 2005, pp. 314-319. doi:10.1016/j.nima.2005.07.073

- [53] B. N. Zaveryukhin, S. A. Mirsagatov, N. N. Zaveryukhina, V. V. Volodarski and E. B. Zaveryukhina, "Cadmium Telluride Thin-Film Detectors of Nuclear Radiation," *Technical Physics Letters*, Vol. 29, No. 11, 2003, pp. 959-962. <u>doi:10.1134/1.1631378</u>
- [54] X. Wu, "High-Efficiency Polycrystalline CdTe Thin-Film Solar Cells," *Solar Energy*, Vol. 77, No. 6, 2004, pp. 803-814. doi:10.1016/j.solener.2004.06.006
- [55] M. Burgelman, P. Nollet and S. Degrave, "Modelling Polycrystalline Semiconductor Solar Cells," *Thin Solid Films*, Vol. 361-362, 2000, pp. 527-532. http://users.elis.ugent.be/ELISgroups/solar/projects/scaps. html